IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Reissue patent application of :

Oh-Sung SONG et al. : BOX REISSUE

Serial No. (new)¹ :

Filed June 30, 2003 :

METHOD FOR FABRICATING MOS SEMICONDUCTOR DEVICE HAVING SALICIDE REGION AND LDD REGION

AMENDMENT ACCOMPANING REISSUE APPLICATION

Honorable Commissioner For Patents Washington, D.C. 20231

Sir:

Concurrently with the filing of the above-identified reissue application, the following amendments and remarks are submitted:

In the Claims

Kindly add the following new Claims 9-17:

9. (New) A method for fabricating a metal oxide semiconductor (MOS) transistor, comprising:

¹ This is a reissue application of U.S. Patent No. 6,255,181 B1, issued July 3, 2001.